CLAIMS

- An optical phase delay device for providing phase delayed optical outputs comprising:
- at least two parallel covering plates having a physical separation in between;
 regions of polymer materials spaced by a distance substantially smaller than one
 micrometer;
 - regions of liquid crystal particles interleaving the said regions of polymers; and a group of electrodes being fabricated near the said covering glass plates.
- 2. The optical phase delay device recited in claim 1 wherein the said covering plates being glass plates.
- 3. The optical phase delay device recited in claim 1 wherein the said liquid crystal regions having an ordinary refractive index n_0 and an extraordinary refractive index n_e .
- 4. The optical phase delay device recited in claim 1 wherein the said polymer regions having an index of refraction n_{p} .
- The optical phase delay device recited in claim 1 wherein the said polymer regions and liquid crystal regions being fabricated through a photolithography method.
- 6. The optical phase delay device recited in claim 1 wherein the said liquid crystal regions containing liquid crystal materials.
- 7. The optical phase delay device recited in claim 1 wherein the said polymer regions and liquid crystal regions being fabricated through a photolithography method using patterned phase masks and/or using patterned holographic two beam interference methods.
- 8. The optical phase delay device recited in claim 1 wherein the said electrodes being fabricated with electrically conductive materials such as metals, ITO (Indium-Tin oxide), and/or conductive polymeric mixtures.
- 9. The optical phase delay device recited in claim 1 wherein the said electrodes being fabricated through a photolithography method.

- 10. The optical phase delay device recited in claim 1 wherein the said cover plate being optically coupled to at least one polarization beam splitters.
- 11. The optical phase delay device recited in claim 1 wherein the said cover plate being optically coupled to at least one prism.
- 12. The optical phase delay device recited in claim 1 wherein the said polymer regions having separations measuring from 1 to 1000 nanometers.
- 13. The optical phase delay device recited in claim 1 wherein the said cover plates having a separation distance of 1 micrometers to 500 micrometers.
 - 14. A method for providing optical phase delay comprising the following steps: using a collimated light source having specific wavelength;
- passing the input light to an electrically tuned liquid crystal nano-structure consisting of alternating polymer and liquid crystal regions;
- applying electrical voltages to electrodes near the said liquid crystal nanostructure to tune the said optical phase delay.
- 15. The method recited in claim 14 wherein the said liquid crystal regions having an ordinary refractive index n_o and an extraordinary refractive index n_e .
- 16. The method recited in claim 14 wherein the said polymer regions having an index of refraction n_p .
- 17. The method recited in claim 14 wherein the said polymer regions and liquid crystal regions being fabricated through a photolithography method.
- 18. The method recited in claim 14 wherein the said liquid crystal regions containing liquid crystal materials.
- 19. The method recited in claim 14 wherein the said polymer regions and liquid crystal regions being fabricated through a photolithography method using patterned phase masks and/or using holographic two beam interference methods.
- 20. The method recited in claim 14 wherein the said the said electrodes being fabricated with electrically conductive materials such as metals, ITO (Indium-Tin oxide), and/or conductive polymeric mixtures.

- 21. The method recited in claim 14 wherein the said liquid crystal regions being optically coupled to at least one polarization beam splitters.
- 22. The method recited in claim 14 wherein the said polymer regions having separations measuring from 1 to 1000 nanometers.
- 23. The method recited in claim 14 wherein the said cover plates having a separation distance of 1 micrometers to 500 micrometers.